

2/12/04

Form PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	ATTY. DOCKET NO. 0171-1063P	APPLICATION NO. NEW
APPLICANT OHSAWA, Youichi et al		
FILING DATE February 12, 2004		GROUP

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	Kind	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
ITP	US 2,354,229		1994-07-25	Walter et al.	568	56	
ITP	US 6,261,738	B1	2001-07-17	Asakura et al.	430	270.1	
ITP	US 6,004,724	A	1999-12-21	Yamato et al.	430	281.1	
ITP	US 5,338,641		1994-8-16	Pawlowski et al.	430	165	

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	Office	DOCUMENT NUMBER	Kind	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
								YES	NO
ITP	JP	3-103854	A	1991-04-30	JAPAN			ABS	
↑	JP	10-90884	A	1998-04-10	JAPAN			ABS	
	JP	2001-55373	A	2001-02-27	JAPAN			ABS	
	JP	2001-106669	A	2001-04-17	JAPAN			ABS	
	JP	8-123032	A	1996-05-17	JAPAN			ABS	
	JP	11-72921	A	1999-03-16	JAPAN			ABS	
	JP	11-38604	A	1999-02-12	JAPAN			ABS	
↓	JP	6-266112	A	1994-09-22	JAPAN			ABS	
ITP	JP	4-211258	A	1992-08-03	JAPAN			ABS	

OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.)

ITP	Leo A. Paquette, J. Am. Chem. Soc., Vol 86, pages 4383-4385, (October 20, 1964)
↑	Walter et al., J. Am. Chem. Soc., Vol. 67, pages 655-657, (April 1945)
	Wagner et al., Synthetic Organic Chemistry, John Wiley & Sons, Inc., 1965, pages 778-781
	Arimitsu et al., J. Photopolym. Sci. and Tech., Effect of Phenolic Hydroxyl Residues on the Improvement of Acid-Proliferation-Type Photoimaging Materials., pages 29 & 30 (1996)
	Arimitsu et al., J. Photopolym. Sci. and Tech., Sensitivity Enhancement of Chemical-Amplification-Type Photoimaging Materials By Acetoacetic Acid Derivatives, Vol 8, Number 1, pages 43 & 44, Number 1 (1995)
ITP	Kudo et al., J. Photopolym. Sci. and Tech., Enhancement of the Sensitivity of Chemical-Amplification-type Photoimaging Materials by β -Tosyloxyketone Acetals, Vol. 8, Number 1 pages 45-46, (1995)

EXAMINER <i>Fiona T. Powers</i>	DATE CONSIDERED <i>11/14/05</i>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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JTP	US 5,945,517		1999-8-31	Nitta et al.	534	558			
↑	US 5,908,730		1999-6-1	Nitta et al.	430	170			
↓	US 5,558,971		1996-9-24	Urano et al.	430	170			
↓	US 6,136,502		2000-10-24	Satoshi et al.	430	270-1			
JTP	US 5,558,976		1996-9-26	Urano et al.	430	326			
FOREIGN PATENT DOCUMENTS									
	Office	DOCUMENT NUMBER	Kind	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
								YES	NO
JTP	JP	2000-344836	A	2000-12-12	JAPAN			ABS	
↑	JP	11-190904	A	1999-7-13	JAPAN			ABS	
↓	JP	2906999	B2	1999-4-2	JAPAN			ABS	
↓	JP	2000-314956	A	2000-11-14	JAPAN			ABS	
↓	JP	9-301948	A	1997-11-25	JAPAN			ABS	
↓	JP	9-95479	A	1997-4-8	JAPAN			ABS	
↓	JP	9-230588	A	1997-9-5	JAPAN			ABS	
JTP	JP	9-208554	A	1997-8-12	JAPAN			ABS	
OTHER DOCUMENTS (Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.)									
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